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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the Application of: **Ken SAWADA et al.**

Art Unit: 1795

Application Number: 10/804,179

Examiner: **Kathleen Duda**

Filed: **March 19, 2004**

Confirmation Number: 6768

For: **RESIST PATTERN FORMING METHOD AND SEMICONDUCTOR DEVICE
FABRICATION METHOD**

Attorney Docket Number: **042256**

Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

February 29, 2008


Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated November 1, 2007 for one month from February 1, 2008 to March 1, 2008.

Attached please find a check in the amount of **\$220.00** for the additional claims fee (\$100.00) and the cost of the extension (\$120.00). If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP


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Attachment: Check of \$220.00